Preparation of Performance of Nanosilica-loaded Fluorescent Yellowing Inhibitor in Paper Made from High-yield Pulp

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3-Aminopropyl-trimethoxysilane was introduced into bis-triazinyl aminostilbene through the condensation reaction to obtain fluorescent whitening agents (FWAs) having excellent photo-stability. Tetraethoxysilane was hydrolyzed and combined with FWAs through in situ polymerization to obtain nanosilica-loaded yellowing inhibitors (SiO$_2$–FWAs). Ultraviolet (UV) spectroscopy showed that the ratios of the trans-isomer structure in FWAs after 3 h of UV irradiation was 5.41 times higher than those of the cis-isomer. Moreover, the absorption intensity in the UV region was increased distinctly after nano-silica loading. Fluorescence spectroscopy revealed that the fluorescence of SiO$_2$–FWAs was more intense than that of FWAs. In addition, the fluorescence quantum yield of SiO$_2$–FWAs reached 0.416, whereas that of the default FWAs was only 0.279. UV-aging test results showed that SiO$_2$–FWAs can improve the initial whiteness and anti-yellowing performance of paper made from high-yield pulp (HYP). These results indicated that the as-prepared SiO$_2$–FWAs not only exhibited more excellent UV absorption and fluorescence emission properties, but it also exerted better whitening and anti-yellowing effects on high-yield pulp paper than the default FWAs. The enhanced performance of SiO$_2$–FWAs can be ascribed to the synergy between the excellent UV-scattering effect of nanosilica and the fluorescent whitening property of FWAs.

Keywords: HYP; Yellowing inhibitor; Optical stability; Bistriazinylstilbene derivative; Nanosilica; Brightness

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INTRODUCTION

In order to solve the problems of traditional mechanical pulp such as high production costs, poor strength, low yield, large total amount of chemicals, and difficulty in post-production pollution treatment, scientists explored and invented a high-efficiency, high-quality, low-polluting pulping technology-chemical mechanical pulping in the 1970s and the resulting pulp is called high-yield pulp (HYP). The yield of HYP exceeds 65% and usually contains semi-chemical pulp (SCP), chemical mechanical pulp (CMP), wood chip groundwood pulp (RMP), thermomechanical pulp (TMP), chemical thermomechanical pulp (CTMP), stone groundwood pulp (SGW), pressed stone groundwood pulp (PGW) and other paper pulp. Among them, the alkaline peroxide mechanical pulp(APMP), established on the basis of BCTMP, introduced by ASB in the 1990s is favored by the paper industry, which yield is as high as 85% to 95%. In addition, compared with chemical pulp,
yield pulp has obvious characteristics of high whiteness, high strength, low fiber bundle and high printing quality, so the obtained paper products are put into the production of newsprint, coated base paper and other cultural papers. Furthermore, APMP pulping greatly simplifies the traditional pulping process, and can also save a lot of costs, which has a good development prospect. Therefore, HYP is widely used in paper industry to address the shortages of wood resource, alleviate environment deterioration, and reduce production waste (Liu et al. 2012; Wang et al. 2013; Liu et al. 2016; Li et al. 2017). However, the unseparated lignin in HYP can easily lead to yellow reversion with ambient light irradiation, and this restricts the application of HYP in high-quality paper (Cannell and Cockram 2000; Rundlöf et al. 2002; Manda et al. 2012; Vänskä et al. 2016). Herein, a yellowing inhibitor, used to suppress the color reversion of HYP, is an effective way to expand the usage of HYP paper (Um et al. 2006; Zhang et al. 2013; Guo et al. 2017).

To introduce additives having the ability to absorb ultraviolet (UV) light and/or free-radical elimination function has been reported to be one of the most effective and economical ways to suppress the color reversion of HYP, and such an approach also is relatively easy to implement industrially (Eltoni et al. 2006; Smt et al. 2013; Turkovic et al. 2016). One of the most used additives is fluorescent brighteners (FWAs), which are also used for pulp whitening in the paper industry and cotton industry due to the superior whitening performance and relatively low cost (Konstantinova et al. 1999; Hörsch et al. 2003; Lee et al. 2005; Fan et al. 2007; Jung and Kang 2013). Even so, the primary disadvantages of FWAs are their poor stability in long-term irradiation, low yellowing point, and sensitivity to sunlight (Konstantinova et al. 1999; Chen et al. 2014). To overcome the draw-backs of FWAs, numerous researchers have introduced fluorescent molecules to improve the photostability via steric hindrance in polymerization systems (Hussain et al. 2009; Saeed et al. 2014). Liu and Zhang (2011) synthesized an asymmetrical polymeric FWA and showed that its photostability has drastically improved after polymerization. Zheng et al. (2016) also prepared a polymeric FWA that was based on the 4,4'-diaminostilbene-2,2'-disulfonic (DSD) acid-triazine structure, which can improve the photostability and enhance the brightness, surface strength, and smoothness of paper. Based on the above mechanism on color reversion, the most important factor is FWAs (inhibitors) that shield the UV light (convert the absorbed UV light to thermal energy). By absorbing the UV light energy before it reached the lignin, the lignin that remains in HYP not be damaged by the UV light from sunlight. Nevertheless, the use of FWAs to restrain the color reversion of HYP fails to enable long-term inhibition performance, and bare organic molecules are easily decomposed under ambient light irradiation for long durations.

Nanosilica is an excellent UV shielding agent with high reflectivity of more than 70%, superior biocompatibility, and thermal insulation properties (Medda and De 2009; Strauchs et al. 2012; Tang et al. 2012). In this paper, a nanosilica-loaded yellowing inhibitor was prepared. Here, KH-540, a silane coupling agent, was used as a bridging group to introduce FWAs into nanosilica through in-situ polymerization. The steric hindrance of KH-540 can improve photo stability by effectively inhibiting the photo isomerization of FWAs. Moreover, the unique UV absorption properties of nanosilica and FWAs can drastically delay the photo-aging of HYP paper.
EXPERIMENTAL

Materials
All chemicals, such as KH-540, tetraethoxysilane (TEOS), cyanuric chloride, 4,4'-diaminostilbene-2,2'-disulfonic acid (DSD acid), sodium hydroxide, absolute ethyl alcohol, acetone, and morpholine were purchased from Aladdin. All chemicals used were of industrial or analytical grade and used without further purification.

Methods
Synthesis of DSD acid–triazine fluorescent intermediate
First, DSD acid (0.0083 mol) in 5% NaOH solution (20 mL) was dropped into a solution of cyanuric chloride (0.0166 mol) in acetone (40 mL) at 0 °C to 5 °C. The pH of the system was maintained in the range 5 to 6 with NaOH (10%). The reaction mixture was stirred at 0 to 5 °C for 2 h. The temperature was then increased to between 35 and 40 °C. Morpholine (0.0166 mol) was then added, and the mixture was stirred for another 2 h. The pH of the mixture was maintained at 7 to 8. Then, KH-540 (0.0166 mol) was added to the reaction flask. The reaction mixture was heated to 80 °C for 4 h, and its pH was controlled at 9 to 10. Acetone was removed from the mixture through distillation. A precipitate was obtained after washing with acetone and filtration, and drying at 40 °C for 24 h.

The precipitate (5 g) was added to a mixture of deionized water (20 g) and anhydrous ethanol (20 g) in a three-necked flask. The reaction mixture was stirred at 60 °C for 6 h while its pH was maintained in the range 11 to 12 with NaOH (10%). After washing with anhydrous ethanol and filtration, and drying at 45 °C for 24 h, the FWAs were finally obtained. The synthetic route of FWAs is shown in Fig. 1: Yield: 82.6%, I.R. (KBr): 3378 cm⁻¹ (N–H and O–H stretching); 2930, 2885 cm⁻¹ (CH₂-stretching); 1618, 1572, 1505 and 1481 cm⁻¹ (Ar stretching); 1356 cm⁻¹ (C–N stretching); 1171 cm⁻¹ (–SO₃H stretching); 1125 cm⁻¹ (–CH₂–O–CH₂–stretching); and 800 cm⁻¹ (Si–O stretching).

Preparation of SiO₂ and SiO₂-loaded fluorescent antiyellowing agent
Anhydrous ethanol (50 mL), deionized water (1.0 mL), TEOS (1.5 mL), and ammonia (1.7 mL) were added to a three-necked flask in accordance with a previously reported protocol for in-situ polymerization (Liang et al. 2016). The mixture was then stirred at 40 °C for 2 h. Then, aliquots of the aqueous solution containing different mass fraction of FWAs (0.10, 0.12, 0.14, 0.16, and 0.18 wt% of TEOS) were added drop-wise into the reaction system and reacted under uniform stirring at a rate of 700 rpm. Light-yellow powders were obtained after 24 h of stirring at 40 °C by removing residual FWAs and TEOS through three cycles of circulation in ethanol and drying in a vacuum oven at 40 °C for 48 h. Yield: 40.3%. I.R. (KBr): 3448 cm⁻¹ (O–H stretching); 3234 cm⁻¹ (N–H stretching); 2972 cm⁻¹ (CH₂–stretching); 1536 cm⁻¹ (Ar stretching); 1095 cm⁻¹ (Si–O–Si stretching); 958 cm⁻¹ (Si–OH stretching); and 800 cm⁻¹ (Si–O stretching).

Nanosilica was prepared in reference to the first step of the preparation method of SiO₂–FWAs (Liang et al. 2016). The target product was obtained after three cycles of centrifugation/redispersion in ethanol after 12 h of reaction followed by drying in a vacuum oven at 40 °C for 48 h. Yield: 79.3%. I.R. (KBr): 3656 cm⁻¹(O–H stretching); 1095cm⁻¹ (Si–O–Si stretching); 958 cm⁻¹ (Si–OH stretching); and 800 cm⁻¹ (Si–O stretching).
**Preparation of handsheets for the UV-accelerated aging test**

Handsheets (100 g/m²) for the UV-accelerated aging test were prepared in accordance with TAPPI methods (T205 SP-95) by using poplar APMPPulp (Yueyang Paper Co., Ltd, Shanghai, China) and the yield is about 88%. Surface sizing material was prepared by using 4% starch solution that had been heated at 95 °C for 30 min. Then, different contents of synthesized compounds were added. The handsheets were coated on the sizing materials by using a coating machine (ST-1-260, Shaanxi University of Science and Technology, China). The paper samples were dried at room temperature away from light. The test method for paper brightness has been described in a previous work (Zhang et al. 2016).
Characterization

The structures of the prepared samples were characterized through Fourier transform infrared (FTIR, Vector-22, Bruker Corporation, Berlin, Germany) and X-ray photoelectron spectroscopy (XPS, Axis Supra, Kratos, Manchester, UK). Surface morphology was observed through transmission electron microscopy (TEM, FEI Tecnai G2 F20 S-TWIN, PEI, New York, USA). Optical performance was quantified by using an UV–visible spectrometer (UV–Vis, Cary100, Agilent, Santa Clara, USA) and fluorescent phosphorescence pyrolysis spectrometer (FluoroMax-4P, HORIBA, Tokyo, Japan). The brightness of handsheets was quantified by using a colorimeter (dominant wavelength: 425±5 nm) (ZB-A, Hangzhou Zhibang Instrument Co., Ltd., Hangzhou, China). The particle size distribution of nanocomposites was determined by a nanoparticle size surface potential analyzer (Zetasizer, NANO-ZS90, Quantachrome, Florida, USA). The UV-accelerated aging test was performed by using a ZN-100N desktop UV light resistance climate chamber (Xi’an Tongsheng Instrument Manufacturing Co. Ltd, China). The handsheets used in the experiment were prepared by using a sheet former (Shaanxi University of Science and Mechanical Equipment Factory, Xi’an, China).

RESULTS AND DISCUSSION

Structure and Morphology of SiO$_2$–FWAs

The XPS wide spectra (A), relative elemental contents (B), and Si2p spectra of FWAs and SiO$_2$–FWAs(C) are shown in Fig. 2, respectively. Figure 2A shows that both compounds contained elemental Si, and the relative Si content of SiO$_2$–FWAs was considerably higher than that of FWAs. The relative elemental contents of the FWAs and SiO$_2$–FWAs in the XPS wide spectra are shown in Fig. 2B. The C content of SiO$_2$–FWAs had decreased. Nevertheless, the significant increase in the O- and Si- contents of SiO$_2$–FWAs compared with that in the O- and Si- contents of FWAs suggests that SiO$_2$–FWAs had been prepared successfully. The XPS Si2p spectra of FWAs and SiO$_2$–FWAs are presented in Fig. 2C, which was in agreement with the above result. As inferred from the XPS Si2p spectra of FWAs, the energies of Si–C and Si–O were 101.7 and 102.9 eV, respectively, whereas those of SiO$_2$–FWAs were 101.9 and 102.7 eV. The relative Si–O content of SiO$_2$–FWAs was higher than that of FWAs. This result illustrates that Si mainly was present in the form of SiO$_2$ (Si2p, 103.3 eV) in the SiO$_2$–FWAs.
Silica and SiO$_2$–FWAs particles were re-dispersed into ethanol for TEM and SEM imaging and particle size analysis. The results are provided in Fig. 3. The TEM images of SiO$_2$ (Fig. 3A) reveal that the size of pure silica particles was approximately 80±10 nm and they had a uniform size distribution. The size of the as-prepared SiO$_2$–FWAs had increased to 110±10 nm relative to that of SiO$_2$. The layer of material covering the surfaces of SiO$_2$–FWAs could be attributed to the uniform cladding of FWAs on the surfaces of SiO$_2$ spheres. The SEM images of SiO$_2$ and SiO$_2$–FWAs (Fig. 3B) showed that numerous bumps were present on the surfaces of SiO$_2$–FWA particles. The surface of pure silica is smoother than that of SiO$_2$–FWAs. In addition, the particle size of nanosilica was approximately 50 nm to 120 nm, and that of SiO$_2$–FWAs was approximately 80 nm to 170 nm. These results indicated that the particle size of silica had increased after modification with FWAs molecules. The above results indicated that the FWAs had successfully coated on the surfaces of nanosilica to form the SiO$_2$–FWAs inhibitor.
Light and thermal stability of SiO₂–FWAs

The light stability and UV absorption property of FWAs were analyzed in aqueous solution after 3 h of UV irradiation. The results are given in Fig. 4A. The two curves appeared similar, and their maximum absorption peaks were located at 348 nm. The coincidence between the absorption peaks indicated that the main structure of the prepared FWAs had not been destroyed by UV irradiation, that UV irradiation had negligible effects on the structure of FWAs. In addition, the as-prepared FWAs exhibited excellent light stability.

Light stability is an important index of the performance of the DSD acid-based FWAs. Trans(C₇)- and cis(C₅)- isomer concentrations were used as the evaluation standard. High C₇/C₅ values indicated good light stability and fluorescence. The percent concentration of cis–trans-isomers in the solution can be expressed using a formula taken from a previous work (Liu and Zhang 2011). As shown in Fig. 4A, the C₇ and C₅ of FWAs after 3 h of UV light irradiation and in the absence of irradiation were 84.4% and 15.6%, respectively, and the C₇/C₅ value was 5.41. These results indicated that FWAs presented good structural stability under UV irradiation. The structures of the cis–trans-isomers of FWAs are shown in Fig. 4B, which shows that the considerable steric hindrance exerted by the NH–(CH₂)₂–Si(OH)₃ group on the structure of FWAs can effectively prevent the occurrence of cis–trans isomerism under UV irradiation.

Figure 4C shows the UV absorption spectra of SiO₂, FWAs, and SiO₂–FWAs in aqueous solution. The blue dotted line, black solid line, and red dotted line are the absorption curves of SiO₂, FWAs, and SiO₂–FWAs, respectively. Pure SiO₂ showed excellent absorption property at wavelengths of less than 300 nm but poor performance at long wavelengths. The absorption peak in the range 250 to 400 nm is the typical peak of FWAs and was considerably stronger than that of pure SiO₂. Compared with that of pure
samples, the intensity of SiO$_2$–FWAs in the whole UV region was increased. The absorption region had expanded to approximately 500 nm. The improvement in absorption property may be caused by the strong absorption induced by the interaction between SiO$_2$ and FWAs and is beneficial for UV light absorption and attenuating paper reversion. Therefore, the good UV-shielding property of the as-prepared SiO$_2$–FWAs confers the superior color-inhibiting property of SiO$_2$–FWAs over that of pure FWAs.

**Fig. 4.** Light stabilities of FWAs in aqueous solution(A); cis–trans-isomerism of FWAs(B); and UV absorption spectra of FWAs, SiO$_2$–FWAs, and SiO$_2$(C)

**Fluorescence spectra of FWAs and SiO$_2$–FWAs**

Fluorescent brightness additives primarily enhance the whiteness and brightness of textiles and papers by increasing UV-blocking properties through absorbing light in the near-UV region and re-emitting light at long wavelengths in the blue and visible regions. The fluorescence spectra of FWAs and SiO$_2$–FWAs are shown in Fig. 5A. The FWAs and SiO$_2$–FWAs can absorb UV light at 355 nm and 357 nm ($\lambda_A$), respectively, and re-emit light at 435 nm and 434 nm ($\lambda_F$) in the blue region, respectively. In addition, the fluorescence intensity of SiO$_2$–FWAs was stronger than that of FWAs. This result indicates that the fluorescence emission performance and conversion rate of UV light absorbed by the as-prepared SiO$_2$–FWAs were higher than those of FWAs. The maximum emission wavelength was almost unchanged and can complement the yellow color of paper for white light emission. Thus, the whiteness of the modified paper persists under ambient or UV light irradiation.

The Stokes shift ($\Delta\sigma$) is a parameter that indicates the difference between the properties and structure of the fluorophores in the ground state $S_0$ and the first excited state $S_1$. Large $\Delta\sigma$ values represent high energy losses in electron transition. The $\Delta\sigma$ values (cm$^{-1}$) were calculated by using Eq (1),
The SiO$_2$–FWAs were more photo stable than FWAs (Wei et al. 2004; Magalhães et al. 2006), as indicated by the considerably higher $\Delta\sigma$ values of FWAs ($\Delta\sigma = 5180.5$ cm$^{-1}$) than those of SiO$_2$–FWAs ($\Delta\sigma = 4969.7$ cm$^{-1}$) (Fig. 5A).

\[
\Delta\sigma = \frac{(\lambda_F - \lambda_A) \times 10^7}{\lambda_F \cdot \lambda_A}
\]

(1)

Figure 5B provides the fluorescence emission spectra of SiO$_2$–FWAs synthesized with various FWAs contents (0.10, 0.12, 0.14, 0.16, and 0.18 wt%). The fluorescence intensity of SiO$_2$–FWAs first increased and then decreased as the FWAs loading content was increased. The optimal FWAs content was 0.14wt% given that it provided the maximum fluorescence intensity of $I_F = 6.36 \times 10^6$. This result indicates that the most suitable fluorescent concentration was approximately 0.14 wt%. The fluorescence spectra of SiO$_2$–FWAs in aqueous solutions with different pH values are displayed in Fig. 5C. Fluorescence intensity first increased and then decreased as the solution pH was increased. The maximum fluorescence emission intensity corresponded to pH=7. Thus, the SiO$_2$–FWAs can be used in neutral-to-alkaline environments. The value of fluorescence quantum yield ($QY$) directly reflects the whitening ability of fluorescent whitener. The calculation method of $QY$ is shown in Eq. (2), and the quinine sulfate ($QY_r=0.55$) was used as reference substance. The $QY$ value of SiO$_2$–FWAs (Fig. 5D) was 0.416, which was higher than that of the default FWA (0.279). This result indicates that the fluorescence emission ability of SiO$_2$–FWAs was better.

\[
QY_S = QY_r \left( \frac{m_S}{m_F} \right) \left( \frac{n_F}{n_S} \right)^2
\]

(2)
In Eq. 2, \( QY_s \) and \( QY_r \) represent the fluorescence quantum yields of the sample and quinine sulfate, respectively. The \( m_s \) and \( m_r \) denote the slope of the fitted line of integrated fluorescence intensity and the corresponding absorbance of the sample, respectively. The \( n_s \) and \( n_r \) are the refractive index of the solution of the sample (water, 1.325) and quinine sulfate (0.1mol/L sulfuric acid, 1.369), respectively.

**SEM images of SiO\(_2\)–FWAs applied to paper surfaces**

The SiO\(_2\)–FWAs were dispersed into starch solution at a mass fraction of 1.0% and coated on the surfaces of handsheets. The surface morphology of the handsheets was then investigated. The results for the blank sample (A) and sample treated with SiO\(_2\)–FWAs (B) are shown in Fig. 6. The large number of filiform fibers (red dotted circle) on the surfaces of blank handsheets (Fig. 6A) resulted from fiber tearing and oxidation during processing. These filamentous fibers easily undergo reversion upon exposure to UV light. Reversion is the primary reason for the yellowing of HYP paper. As illustrated in Fig. 6B, the surfaces of paper fibers become covered with a layer of SiO\(_2\)–FWAs nanospheres upon treatment with SiO\(_2\)–FWAs. The as-prepared SiO\(_2\)–FWAs can prevent light from irradiating the surface of paper directly and suppresses paper aging. Moreover, SiO\(_2\)–FWAs can improve initial paper brightness by converting absorbed UV light to blue fluorescent light, which complements yellow light to enable white light emission. The above analysis shows that SiO\(_2\)–FWAs is an excellent inhibitor for preventing yellowing of HYP paper. It exhibits UV-shielding properties and fluorescent whitening performance.

![SEM images of SiO\(_2\)–FWAs applied to paper surfaces](image-url)

**Fig. 6.** SEM images of blank paper (A) and paper treated with SiO\(_2\)–FWAs (B)
Changes in the surface brightness of paper sheets under UV irradiation

Brightness and yellowing value (PC values) are important parameters for evaluating the antiyellowing performance of paper. Therefore, the brightness of handsheets coated with SiO$_2$–FWAs and FWAs was quantified, and PC values were calculated in reference to a previous work (Liu et al. 2015). The PC values of sheets coated with SiO$_2$–FWAs and FWAs were compared with those of blank paper sheets.

The SiO$_2$–FWAs were added at different concentrations (0.0, 0.2, 0.4, 0.6, 0.8, 1.0, 1.2, and 1.4 wt%) to starch solutions and coated on handsheets surface to prepare samples for the evaluation of antiyellowing performance. The samples were dried at room temperature, and their brightness was tested. The results are shown in Fig. 7A. The initial brightness of handsheets treated with SiO$_2$–FWAs was higher than that of blank paper. The brightness of the tested paper coated with 0.2 wt% SiO$_2$–FWAs had increased from 75.5 ISO% (blank paper) to 77.1 ISO%. In addition, the brightness of the paper sheets first increased with increasing concentration, and the whiteness value of the paper coated with 1.0 wt% SiO$_2$–FWAs was 79.4 ISO%, which is higher than that of the blank paper (a difference of 3.9 ISO%). The gradual reduction in the brightness of the paper with the further increase in coating concentration was attributed to the fluorescence quenching of SiO$_2$–FWAs. The above analysis indicates that the optimal coating concentration of SiO$_2$–FWAs was 1.0 wt%.

The changes in the brightness and PC values of coated and uncoated paper sheets after irradiation are shown in Figs. 7B and 7C. The handsheets treated with SiO$_2$–FWAs exhibited the highest brightness value of 79.2 ISO%, which was higher than that of blank (change by 2.7%) and FWAs-coated sheets (0.94%). After 38 h of aging, the brightness of blank paper, FWAs-coated, and SiO$_2$–FWAs-coated sheets were decreased to 59.9 ISO%, 66.3 ISO%, and 68.5 ISO%, respectively, with relative reduction rates of 16.6%, 11.9%, and 10.7%, respectively. These results indicated that the ability of SiO$_2$–FWAs to increase brightness and inhibit aging was superior to that of FWAs and demonstrated that nanosilica can effectively improve the paper-brightening performance of FWAs. Figure 7C shows that the SiO$_2$–FWAs-coated paper had the lowest PC value, followed by FWAs-coated paper. The blank paper sheets exhibited the highest PC value. Therefore, SiO$_2$–FWAs demonstrate good antiyellowing performance.

**Fig. 7.** Brightness of paper treated with different concentrations of SiO$_2$–FWAs(A) (Coating weights of the starch solution was 0.4 g/m$^2$, and the SiO$_2$–FWAs contents were 0.0, 0.2, 0.4, 0.6, 0.8, 1.0, 1.2 and 1.4 wt%, and the FWAs in SiO$_2$–FWAs was 0.14% wt% TEOS). Changes in the brightness (B); and PC (C) of paper sheets as a function of UV irradiation time (SiO$_2$–FWA content was 1.0 wt%).
Antiyellowing mechanism of action in HYP paper

The brightness and tristimulus values of paper sheets aged for different durations were measured by using a whiteness meter, and the corresponding chromaticity coordinates were then calculated (Table 1). The trend shown by the yellowing of sheets under ultraviolet light is described by the 1931-CIE chromaticity coordinates (as shown in Fig. 8). In the 1931-CIE image, point a (0.3561, 0.3450) and point b (0.3669, 0.3511) are the color coordinates of the paper sheets before and after 16 h of UV aging, respectively. The gradual movement of the color coordinate of the paper sample away from the white light point c (0.3300, 0.3300) to the yellow light area during UV aging indicates that the paper sample had undergone yellowing. The chromaticity coordinate of SiO$_2$–FWAs (0.1574, 0.1078) was obtained by importing its fluorescence emission spectral data into CIE software and is shown in the 1931-CIE image. It is located in the blue region. The straight line drawn through points s and c shows that the chromaticity coordinate points a and b of the paper are located near the extension cord of line c–s. This result shows that SiO$_2$–FWAs exerted a good physical whitening effect on the paper sample.

Table 1. Brightness and Relevant Parameters of Paper Sheets at Different Light Irradiation Times

<table>
<thead>
<tr>
<th>Aging Time (h)</th>
<th>Brightness (ISO%)</th>
<th>Tristimulus Values</th>
<th>Chromaticity Coordinates</th>
</tr>
</thead>
<tbody>
<tr>
<td></td>
<td></td>
<td>X</td>
<td>Y</td>
</tr>
<tr>
<td>0</td>
<td>69.75</td>
<td>82.53</td>
<td>79.95</td>
</tr>
<tr>
<td>2</td>
<td>67.28</td>
<td>81.66</td>
<td>78.89</td>
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<tr>
<td>4</td>
<td>66.07</td>
<td>81.30</td>
<td>78.29</td>
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</tr>
<tr>
<td>12</td>
<td>62.67</td>
<td>79.60</td>
<td>76.41</td>
</tr>
<tr>
<td>16</td>
<td>61.46</td>
<td>79.25</td>
<td>75.84</td>
</tr>
</tbody>
</table>

Fig. 8. 1931-CIE image of paper yellowing and color coordinate of SiO$_2$–FWAs.
The antiyellowing mechanism was inferred on the basis of the above results and is illustrated in Fig. 9. Three reactions occur in the SiO$_2$–FWA-coated paper upon UV irradiation. First, most of the ultraviolet light is absorbed, converted into other forms of energy, and then released to the atmosphere. Second, the FWAs molecules loaded on the surfaces of silica nanospheres absorb UV light and emit blue-violet fluorescence with a wavelength of 420 nm to 480 nm. Finally, the destruction of lignin molecules under direct UV irradiation results in the degradation of lignin and the development of yellow coloration. Furthermore, the blue-violet light emitted by fluorescent molecules complements the yellow light emitted by paper. This complementation results in white light emission. The mechanism for suppressing paper yellowing of as-prepared SiO$_2$–FWAs can be summarized as follows:

![Fig. 9. Yellowing inhibition mechanism of SiO$_2$–FWA](image)

**CONCLUSIONS**

1. The nanosilica-loaded antiyellowing agent SiO$_2$–FWA was successfully prepared by introducing fluorescent whitening agents (FWAs) with silicon hydroxyls on the surfaces of nanosilica particles through *in-situ* polymerization.
2. Optical performance test results indicated that the UV absorption and fluorescence emission performance of the as-prepared SiO$_2$–FWAs were superior to those of pure FWAs.
3. The remarkable whitening and antiyellowing properties of SiO$_2$–FWAs could be attributed to the synergy between silica and FWAs.

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